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JG14 Rec'd PCT/PTO 06 MAY 2005

Date of Deposit: May 6, 2005

Case No. 9905/25

UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

ASPAR et al.

Serial No.: Not Yet Assigned

Filing Date: Herewith

For: METHOD FOR FORMING
A BRITTLE ZONE IN A SUBSTRATE
BY CO-IMPLANTATION

Examiner:

Not Yet Assigned

Group Art Unit:

Not Yet Assigned

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, Virginia 22313-1450

Dear Sir:

In accordance with the duty of disclosure under 37 C.F.R. §1.56 and §§1.97-1.98, and more particularly in accordance with 37 C.F.R. §1.97(b), Applicants hereby cite the following references:

| No. | Date of Publication | Patentee/Applicant/Assignee |
|--|---------------------|-----------------------------|
| US 6,150,239 | 11/21/2000 | Goesele et al. |
| US 6,020,252 | 02/01/2000 | Aspar et al. |
| US 5,374,564 | 12/20/1994 | Bruel |
| FR 2 774 510 A1 | 08/06/1999 | France |
| FR 2 773 261 A1 | 07/02/1999 | France |
| FR 2 767 416 A1 | 02/19/1999 | France |
| FR 2 748 851 A1 | 11/21/1997 | France |
| FR 2 748 850 A1 | 11/21/1997 | France |
| FR 2 681 472 A1 | 03/19/1993 | France |
| WO 00/63965 | 10/26/2000 | PCT |
| WO 99/39378 | 08/05/1999 | PCT |
| EP 0786801 A1 | 07/30/1997 | EPO |
| EP 0801419 A1 | 10/15/1997 | EPO |
| 11-87668 | 03/30/1999 | Japan |
| Agarwal et al., <i>Efficient Production of Silicon-on-Insulator Films by Co-Implantation of He+ with H+</i> , 1998 American Institute of Physics, Volume 72, number 9, March 2, 1998, pp. 1086-1088. | | |

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For the Examiner's convenience, Applicants are enclosing Form PTO-1449 (one sheet), and as each of the listed references is in English, no further commentary is believed to be necessary, 37 C.F.R. §1.98(a)(3). Applicant respectfully requests the Examiner's consideration of the above references and entry thereof into the record of this application.

Also enclosed is a copy of the International Search Report issued on March 19, 2004 for corresponding PCT Application No. PCT/FR03/03256 of the above-identified application.

By submitting this Statement, Applicants are attempting to fully comply with the duty of candor and good faith mandated by 37 C.F.R. §1.56. As such, this Statement is not intended to constitute an admission that any of the enclosed references, or other information referred to therein, constitutes "prior art" or is otherwise "material to patentability," as that phrase is defined in 37 C.F.R. §1.56(a).

Applicants have calculated no fee to be due in connection with the filing of this Statement. However, the Director is authorized to charge any fee deficiency associated with the filing of this Statement to a deposit account, as authorized in the Transmittal accompanying this Statement.

Respectfully submitted,

May 6, 2005


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|---|--------------------------------|---------------------------------------|
| FORM PTO-1449 | SERIAL NO. Not Yet Assigned | CASE NO. 9905/25 (BIF023239/DM) |
| LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT | FILING DATE Herewith | GROUP ART UNIT Not Yet Assigned |
| APPLICANTS: ASPAR et al. | | |

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

| EXAMINER INITIAL | | DOCUMENT NUMBER <small>Number-Kind Code (if known)</small> | DATE | NAME | CLASS/ SUBCLASS | FILING DATE |
|---------------------|----|--|------------|----------------|--------------------|----------------|
| | A1 | 6,150,239 | 11/21/2000 | Goesele et al. | | |
| | A2 | 6,020,252 | 02/01/2000 | Aspar et al. | | |
| | A3 | 5,374,564 | 12/20/1994 | Bruel | | |

FOREIGN PATENT DOCUMENTS

| EXAMINER INITIAL | | DOCUMENT NUMBER <small>Number-Kind Code (if known)</small> | DATE | COUNTRY | CLASS/ SUBCLASS | TRANSLATION YES OR NO |
|---------------------|-----|--|------------|---------|--------------------|--------------------------|
| | A4 | FR 2 774 510 A1 | 08/06/1999 | France | | |
| | A5 | FR 2 773 261 A1 | 07/02/1999 | France | | |
| | A6 | FR 2 767 416 A1 | 02/19/1999 | France | | |
| | A7 | FR 2 748 851 A1 | 11/21/1997 | France | | |
| | A8 | FR 2 748 850 A1 | 11/21/1997 | France | | |
| | A9 | FR 2 681 472 A1 | 03/19/1993 | France | | |
| | A10 | WO 00/63965 | 10/26/2000 | PCT | | |
| | A11 | WO 99/39378 | 08/05/1999 | PCT | | |
| | A12 | EP 0786801 A1 | 07/30/1997 | EPO | | |
| | A13 | EP 0801419 A1 | 10/15/1997 | EPO | | |
| | A14 | 11-87668 | 03/30/1999 | Japan | | Abstract |

| EXAMINER INITIAL | OTHER ART – NON PATENT LITERATURE DOCUMENTS <small>(Include name of author, title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date page(s), volume-issue number(s), publisher, city and/or country where published.)</small> | |
|---------------------|---|--|
| | A15 | Agarwal et al., <i>Efficient Production of Silicon-on-Insulator Films by Co-Implantation of He+ with H+</i> , 1998 American Institute of Physics, Volume 72, number 9, March 2, 1998, pp. 1086-1088. |

| | |
|----------|-----------------|
| EXAMINER | DATE CONSIDERED |
|----------|-----------------|

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.